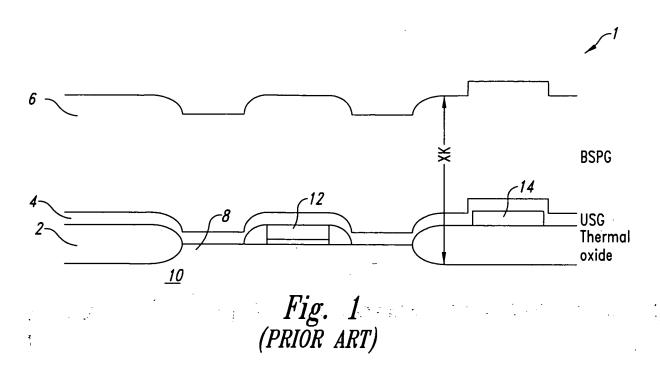
Title: SEMICONDUCTOR STRUCTURE HAVING AN IMPROVED PRE-METAL DIELECTRIC STACK AND METHOD FOR FORMING THE SAME Inventor(s): Shin Hwa Li et al. Express Mail No. EV336594065US Docket No. 98-P-009D1 (850063.529D1)



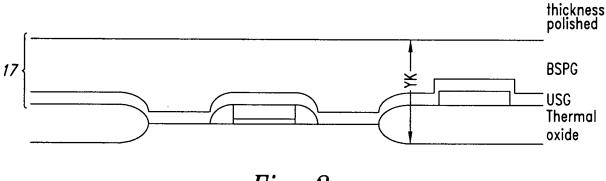


Fig. 2 (PRIOR ART)

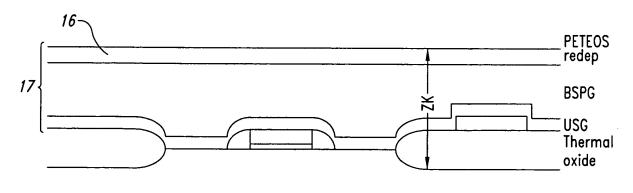


Fig. 3 (PRIOR ART)

Title: SEMICONDUCTOR STRUCTURE HAVING AN IMPROVED PRE-METAL DIELECTRIC STACK AND METHOD FOR FORMING THE SAME Inventor(s): Shin Hwa Li et al. Express Mail No. EV336594065US Docket No. 98-P-009D1 (850063.529D1)

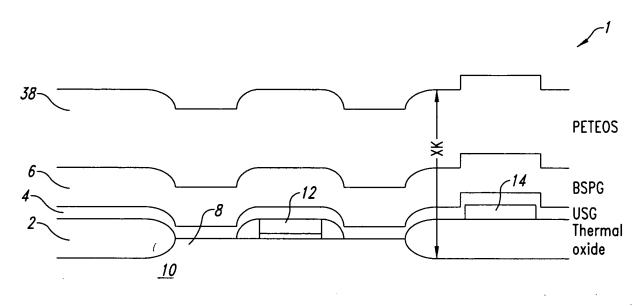


Fig. 4

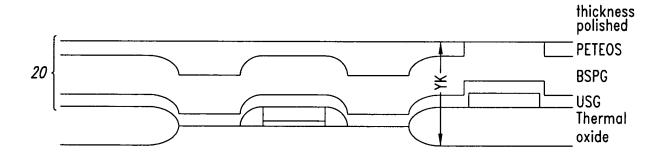


Fig. 5

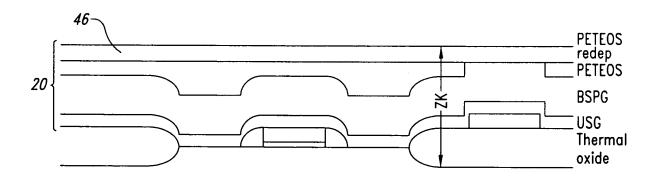


Fig. 6